

Search Notes

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	154	gate adj insulation with ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 18:39
L2	113	gate adj insulation adj film with ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 18:39
L3	1773	438/694	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:21
L4	654	438/695	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:21
L5	1846	438/745	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:22
L6	543	438/775	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:22
L7	246	438/776	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:22
L8	933	438/770	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:22
L9	81	plasma with nitridation and ono and time	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:23

L10	141	acid and plasma with oxidation and ono and time	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:23
L11	43	nitric with acid and plasma with oxidation and ono and time	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:24
S1	1	nitric adj acid and plasma with nitridation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 18:38
S2	28	nitric adj acid and plasma with nitridation	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/15 23:29
S3	76	plasma with nitridation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:23
S4	11	acid and plasma with nitridation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/15 23:33
S5	1	nitric with acid and plasma with nitridation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/15 23:30
S6	2	nitric same acid and plasma with nitridation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/15 23:30
S7	97	acid and plasma with oxidation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:23
S8	19	nitric with acid and plasma with oxidation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:23

S9	6932	nitric adj acid same oxidation	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 11:52
S10	4293	nitric adj acid with oxidation	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 11:52
S11	795	nitric adj acid with oxidation with oxide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 11:52
S12	20	nitric adj acid with oxidation with oxide with silicon	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:01
S13	0	nitric adj acid with oxidation with oxide adj silicon	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:01
S14	68	nitric adj acid with oxidation with silicon	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:01
S15	22	nitric adj acid with oxidation with silicon and plasma	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:42
S16	0	nitric adj acid with oxidation with silicon and plasma and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:01
S17	192	low adj temperature with nitridation	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:42
S18	36	low adj temperature with plasma near nitridation	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:50

S19	12	low adj temperature with plasma near nitridation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:50
S20	13	low with temperature with plasma near nitridation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/20 12:50
S21	1	"5937310".PN.	USPAT; USOCR	OR	ON	2005/03/20 13:01
S22	1	"5834351".PN.	USPAT; USOCR	OR	ON	2005/03/20 13:01
S23	18	nitric adj acid and plasma with oxidation and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/21 07:38
S28	25	acid and plasma with oxidation same temperature and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/21 07:39
S29	3	nitric with acid and plasma with oxidation same temperature and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/21 07:40
S30	9	acid and plasma adj oxidation same temperature and ono	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/21 08:19
S31	1825	438/694	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:21
S32	735	438/695	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:21
S33	1743	438/745	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:21

S34	510	438/775	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:22
S35	232	438/776	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:22
S36	929	438/770	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/15 19:22